

## Features of the Thermoelectrical Power in CuInSe<sub>2</sub> Monocrystals.

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The results of research on thermoelectrical power ( $a$ ) in CuInSe<sub>2</sub> monocrystals in the temperature range 77-293 K before and after annealing are presented. The annealing monocrystals grown by the Bridgman method is carried out at  $T=550^{\circ}\text{C}$  for 3 hours in the air. Samples p- and n-CuInSe<sub>2</sub> have a mobility  $\mu_p=80$  cm/B $\times$ c and  $\mu_n=200$  cm/B $\times$ c and a carriers concentration  $p=2\times 10^{16}$  cm<sup>-3</sup> and  $n=5\times 10^{17}$  cm<sup>-3</sup> at  $T=293\text{K}$ . On the temperature dependences of  $a_p$  and  $a_n$  are observed minima at  $T_{pmin}=120\text{K}$  and  $T_{nmin}=140\text{K}$ . At  $T_{pmax}=220\text{K}$  and  $T_{nmax}=240\text{K}$   $a_p=0,769$  mV and  $a_n=0,326$  mV. The annealing leads to increase of  $a_p$  and decrease of  $a_n$  and to low temperature smoothing of a maxima. The increase of  $a$  in a range  $120\text{K}<T<220\text{K}$  for  $a_p$  and  $140\text{K}<T<240\text{K}$  for  $a_n$  is agreed with the theory of charge carriers transport by optic phonons [1]. The increase of  $a_p$  at  $T<120\text{K}$  and  $a_n$  at  $T<140\text{K}$  can be explained by an effect of charge carriers transport by acoustic phonons. The  $a$  decreases at  $T>T_{pmax}$  ( $T_{nmax}$ ). Authors [2] observed the analogous dependence for the mobility of charge carriers that is connected with rising of diffusion contribution on thermal lattice oscillations.

The annealing leads to decrease of defects concentration and “doping” by oxygen of air. This affects the increase of  $a_p$  connected with rising of holes concentration and the decrease of  $a_n$  owing to reducing of electrons concentration. The smoothing of a minima can be explained by influence of crystal lattice defects bringing in by oxygen and rising of charge carriers diffusion.

[1] M.J. Fedorov, V.K. Zaitsev, V.V Popov., A.E. Kaleazin, M.A. Hazan, J.V. Ivanov Proc. of the XV Int. Conf. on Thermoelectrics. St.Petersburg, 92 (1997)

[2] K.I Bachmann., M. Fearheilei, Y. Shing, N. Tran Appl. Physics Lett. 44, N4, 407 (1984)